## THIS OPINION WAS NOT WRITTEN FOR PUBLICATION

The opinion in support of the decision being entered today was <u>not</u> written for publication and is <u>not</u> binding precedent of the Board.

Paper No. 16

UNITED STATES PATENT AND TRADEMARK OFFICE

BEFORE THE BOARD OF PATENT APPEALS AND INTERFERENCES

Ex parte RAJIV V. JOSHI
and MANU J. TEJWANI

Appeal No. 1998-1095 Application No. 08/367,565

ON BRIEF

Before HAIRSTON, BARRETT, and BLANKENSHIP, <u>Administrative</u> <u>Patent Judges</u>.

HAIRSTON, Administrative Patent Judge.

# DECISION ON APPEAL

This is an appeal from the final rejection of claims 1 through 3, 5 through 14, 16 through 20, 39 and 40.

The disclosed invention relates to a soft metal conductor. The soft metal in the soft metal conductor is selected from the group consisting of Al, Cu and Ag.

Claim 1 is illustrative of the claimed invention, and it reads as follows:

1. A soft metal conductor comprising an upper-most layer consisting of grains capable of providing a substantially scratch-free planar surface upon polishing in a subsequent chemical mechanical polishing step, said soft metal is selected from the group consisting of Al, Cu, Ag, binary and ternary alloys of Al, Cu and Ag.

The reference relied on by the examiner is:

Kikkawa 5,345,108 Sept. 6,

1994

Claims 1 through 3, 5 through 14, 16 through 20, 39 and 40 stand rejected under 35 U.S.C. § 102(a) as being anticipated by Kikkawa.

Reference is made to the final rejection, the brief and the answer for the respective positions of the appellants and the examiner.

#### OPINION

The 35 U.S.C. § 102(a) rejection of claims 1 through 3, 5 through 14, 16 through 20, 39 and 40 is reversed.

According to the examiner (Final rejection, page 2),

Kikkawa discloses a first soft metal layer 105 of AlSiCu, and
a second soft metal layer 107 of AlSiCu. The examiner further

states (Final rejection, page 3) that the "process limitations
cannot impart patentability to product claims where the

product is not patentably distinguished over prior art."

Appellants argue (Brief, page 5) that "the present application does not contain any product by process claims."

We agree. The phrase "capable of providing a substantially scratch-free planar surface upon polishing in a subsequent chemical mechanical polishing step" is a statement of intended use of the soft metal conductor, and it is not a process step for making the soft metal conductor per se.

Appellants also argue (Brief, page 6) that:

The present invention teaches a soft metal selected from the group consisting of Al, Cu, Ag, binary and ternary alloys of Al, Cu and Ag. This is equivalent to reciting a soft metal selected from the group consisting of Al, Cu, Ag, AlCu, AgCu, AlAg and AlCuAg. On the other hand, the Kikkawa reference teaches an alloy of AlCuSi wherein Si is not a component presented in any one of the compositions claimed by the Appellant[s]. Moreover, at no place in the Kikkawa patent has [Kikkawa] mentioned that his alloy is a soft metal that is scratch resistant. Furthermore, Kikkawa has not taught, disclosed or suggested the grain size of the alloy particles.

We agree with appellants' arguments. The phrase "consisting of" in the claims limits each of the claims to the elements recited therein. Thus, the claims on appeal are not anticipated by the teachings of Kikkawa because of the presence of Si in the alloy AlSiCu.

## **DECISION**

The decision of the examiner rejecting claims 1 through 3, 5 through 14, 16 through 20, 39 and 40 under 35 U.S.C. § 102(a) is reversed.

## REVERSED

	Kenneth W. Hairston Administrative Patent Jud	) dge ) ) )	
PATENT	Lee E. Barrett	)	BOARD OF
	Administrative Patent Jud	dge ) ) ) )	APPEALS AND INTERFERENCES

<sup>&</sup>lt;sup>1</sup> In <u>Mannesmann Demag Corp. v. Engineered Metal Products</u> <u>Co., Inc.</u>, 793 F.2d 1279, 1282, 230 USPQ 45, 46 (Fed. Cir. 1986), the Court noted that "the phrase 'consisting of' appears in clause (a), not the preamble of the claim, and thus limits only the element set forth in clause (a)."

Howard B. Blankenship
Administrative Patent Judge )

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